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	APPLICATION NO.	I	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
	10/053,572		01/24/2002	Hideto Ohnuma	740756-2422	740756-2422 3447	
	31780	7590	01/18/2005		EXAM	EXAMINER	
	ERIC ROBI	NSON			TAUTS6-2422 EXAMINER KENNEDY, JENNIFE	ENNIFER M	
	21010 SOUTHBANK ST. POTOMAC FALLS, VA 20165				ART UNIT	PAPER NUMBER	
					2812	2812	

DATE MAILED: 01/18/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

<u></u>	<u> </u>		A l
	Application No.	Applicant(s)	7110
Advisory Action	10/053,572	OHNUMA, HIDETO	
•	Examiner	Art Unit	
	Jennifer M. Kennedy	2812	
The MAILING DATE of this communication app	ears on the cover sheet with the	correspondence addi	ress
THE REPLY FILED FAILS TO PLACE THIS AP Therefore, further action by the applicant is required to final rejection under 37 CFR 1.113 may only be either: condition for allowance; (2) a timely filed Notice of Apple Examination (RCE) in compliance with 37 CFR 1.114.	(1) a timely filed amendment wh	cation. A proper repich places the application	cation in
PERIOD FOR R	EPLY [check either a) or b)]		
a) The period for reply expires 3_months from the mailing date of this Ace event, however, will the statutory period for reply expire later to ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f).	lvisory Action, or (2) the date set forth in the han SIX MONTHS from the mailing date of	of the final rejection.	
Extensions of time may be obtained under 37 CFR 1.136(a). The depayed been filed is the date for purposes of determining the period of extelligration of the shortener (b) above, if checked. Any reply received by the Office later than three meanned patent term adjustment. See 37 CFR 1.704(b).	nsion and the corresponding amount of the d statutory period for reply originally set in	e fee. The appropriate ext the final Office action; or	ension fee under (2) as set forth in
1 A Notice of Appeal was filed on Appellant 37 CFR 1.192(a), or any extension thereof (37 CF		•	
2. The proposed amendment(s) will not be entered	because:		
(a) \(\square\) they raise new issues that would require furt	her consideration and/or search	(see NOTE below);	
(b) They raise the issue of new matter (see Note	below);		
(c) they are not deemed to place the application issues for appeal; and/or	in better form for appeal by ma	terially reducing or s	simplifying the
(d) they present additional claims without cance NOTE:	eling a corresponding number of	finally rejected clair	ns.
3. Applicant's reply has overcome the following reje	ection(s).		
Newly proposed or amended claim(s) woul canceling the non-allowable claim(s).	• • • • • • • • • • • • • • • • • • • •	separate, timely filed	d amendment
5. ☑ The a) ☐ affidavit, b) ☐ exhibit, or c) ☑ request f application in condition for allowance because: s		sidered but does NC	OT place the
6. The affidavit or exhibit will NOT be considered be raised by the Examiner in the final rejection.		Y to issues which we	re newly
7.⊠ For purposes of Appeal, the proposed amendment explanation of how the new or amended claims v			and an
The status of the claim(s) is (or will be) as follows	S:		
Claim(s) allowed:			
Claim(s) objected to:	√		
Claim(s) rejected: <u>1-36</u> .			
Claim(s) withdrawn from consideration:			
8. The drawing correction filed on is a) ap	proved or b) disapproved by	the Examiner.	
9. Note the attached Information Disclosure Statem	ent(s)(PTO-1449) Paper No(s).	·	
10. Other:		Jennifer M. Kenned Patent Examiner Art Unit: 2812	runde

U.S. Patent and Trademark Office PTOL-303 (Rev. 11-03)

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Applicant argues examiner's motivation for combining. The examiner maintains that the three criteria for establishing a prima facie case of obviousness has been meet.

First, the examiner has provided a suggestion or motivation to combine from the references themselves. The examiner maintains that it would have been obvious to form the oxide film of Zhang et al. by the method of Ohtani et al. since the examiner notes that Zhang et al. does not disclose a particular method for forming the oxide layer 33, and therefore the particular method used to form the oxide layer lacks criticality in the invention of Zhang et al. One of ordinary skill in the art at the time the invention was made would have recognized that any known method could be used to form the oxide layer 33 in the absence of a particular suggestion by Zhang et al. Ohtani et al. discloses a method of forming a chemical oxide film (see column 2, lines 44-46, and column 6, lines 55-64). Thus, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form the oxide layer of Zhang et al. by the method of Ohtani et al., since the method of forming an oxide layer lacks criticality in the invention of Zhang et al., and since the method of Ohtani is a known method of forming an oxide that improves the surface characteristics of the underlying film (see Ohtani et al. column 2, lines 39-46).

Applicant argues that the fact that there is no method for forming the oxide layer disclosed in Zhang does not mean that any known method could be used to form the oxide layer. The examiner maintains that because Zhang et al. does not disclose a particular method for forming the oxide layer 33 the particular method used to form the oxide layer lacks criticality in the invention of Zhang et al. and that one of ordinary skill

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in the art at the time the invention was made would have recognized that any known method could be used to form the oxide layer 33 in the absence of a particular suggestion by Zhang et al. Nevertheless, the method of Ohtani et al. teaches a method that would have had the advantage of improved surface characteristics of the underlying amorphous silicon layer.

The fact that applicant has recognized another advantage which would flow naturally from following the suggestion of the prior art cannot be the basis for patentability when the differences would otherwise be obvious. See *Ex parte Obiaya*, 227 USPQ 58, 60 (Bd. Pat. App. & Inter. 1985).

Further, the examiner notes that the improved surface characteristics allow for a nickel catalyst to be used In Ohtani et al., which accelerates the crystallization of the amorphous film. The combination of Zhang et al. and Ohtani et al. have also been relied upon to show the limitations of a metal catalyst for crystallization of the amorphous silicon.

Second, there must be a reasonable expectation of success. Since it is clear that the method of Ohtani et al. would form an oxide there is an expectation of success in the method of Zhang, which requires an oxide.

Finally, the prior art reference (or references when combined) must teach or suggest all the claim limitations. The examiner maintains that all limitations have been met by the combination of the Zhang et al. and Ohtani et al. al. as evidenced by the item by item matching in the detailed rejection of the claims.